

Control and characterization of individual grains and grain boundaries in graphene grown by chemical vapour deposition

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The strong interest in graphene has motivated the scalable production of high-quality graphene and graphene devices. As the large-scale graphene films synthesized so far are typically polycrystalline, it is important to characterize and control grain boundaries, generally believed to degrade graphene quality. Here we study single-crystal graphene grains synthesized by ambient chemical vapour deposition on polycrystalline Cu, and show how individual boundaries between coalescing grains affect graphene's electronic properties. The graphene grains show no definite epitaxial relationship with the Cu substrate, and can cross Cu grain boundaries. The edges of these grains are found to be predominantly parallel to zigzag directions. We show that grain boundaries give a significant Raman 'D' peak, impede electrical transport, and induce prominent weak localization indicative of intervalley scattering in graphene. Finally, we demonstrate an approach using pre-patterned growth seeds to control graphene nucleation, opening a route towards scalable fabrication of single-crystal graphene devices without grain boundaries.

The extraordinary properties and potential applications of graphene^{1–3} have motivated the development of large-scale, synthetic graphene grown by various methods, such as graphitization of SiC surfaces^{4,5} and chemical vapour deposition (CVD) on transition metals such as Ni (refs 6–8) and Cu (ref. 9). In particular, it has been shown that large and predominantly monolayer graphene of excellent quality can be synthesized by CVD on polycrystalline Cu foils^{9–11}. This relatively simple and low-cost method has been used to produce graphene that can reach impressive sizes (for example 30 inches, the largest graphene ever made by any method) and that can be easily transferred to other substrates¹⁰. However, the large-scale synthetic graphene films produced so far are typically polycrystalline^{12–14}, consisting of many single-crystalline grains separated by grain boundaries^{15–17}. In the growth of such polycrystalline graphene, graphene grains nucleate from random and uncontrolled locations. As the growth of such grains proceeds, they coalesce and eventually form an interconnected polycrystalline film. The grain boundaries (which, by definition, are defective) are expected to degrade the electrical^{13,14} and mechanical¹⁸ properties of the resulting films. It is well known that the availability of high quality, large single-crystal Si wafers is fundamental to the present Si-based electronics¹⁹. For graphene to realize its promise in 'carbon-based' electronics, it will clearly be necessary to synthesize either large-scale, high-quality

single-crystalline graphene films, or to achieve better control over the nucleation of individual graphene grains and to avoid the grain boundaries in fabricated graphene devices. In this Article, we study graphene grains (either isolated grains or a small number of merged grains) formed during the early stage of ambient CVD growth on Cu foils. We obtain fundamental insight into the growth mechanisms of single-crystalline graphene on polycrystalline Cu substrates. The hexagonally shaped grains (with sizes of tens of micrometres) have their edges macroscopically oriented predominantly parallel to zigzag directions. This display of particular orientations can facilitate studies of crystal direction-dependent phenomena in graphene. We also report measurements of how individual grain boundaries impede electronic transport and scatter charge carriers. Finally we demonstrate controlled graphene nucleation and synthesis of graphene grain arrays that could enable scalable fabrication of devices free of detrimental grain boundaries.

The graphene studied in this work was synthesized on polycrystalline Cu foils by ambient CVD (see Methods), using procedures largely similar to those described in our previous publications^{11,20}. We halted growth before the graphene grains merged with each other to form a globally continuous (but polycrystalline) graphene film^{11,20}. Figure 1a is a typical optical microscopy image of the Cu surface after CVD growth, showing many graphene islands, which consist of either a single grain or a few coalesced grains. Figure 1b

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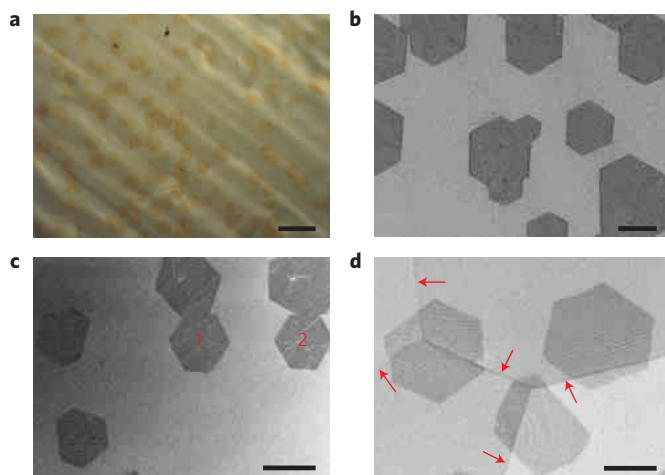


Figure 1 | Graphene grains grown on Cu substrates. **a**, An optical microscopy image of as-grown, mostly hexagonally shaped graphene grains on Cu. Some grains are seen to coalesce to form larger islands. **b**, SEM image of as-grown grains whose edge orientations are approximately aligned with each other. **c**, SEM image of as-grown grains whose edge orientations are not aligned with each other (except for the two grains labelled as 1 and 2). Images **b** and **c** were each taken from within one Cu crystal grain. **d**, SEM image showing that hexagonally-shaped graphene grains can be grown continuously across Cu crystal grain boundaries (indicated by red arrows). The scale bars in **a–d** are 25 μm , 10 μm , 10 μm and 5 μm , respectively.

is a scanning electron microscope (SEM) image of several graphene grains grown within one single Cu grain. The graphene grains were typically hexagonally shaped, with $\sim 120^\circ$ corners, suggesting that their edges are parallel to specific crystallographic directions. The hexagonal shape is notably different from the flower-like shape of previously reported graphene grains grown by low pressure CVD (refs 9,13,21,22) (notably, we also obtain similar flower-shaped graphene grains using our CVD setup operated under low pressure, see Supplementary Fig. S1). A detailed study of the dependence of the shape of graphene grains on various growth conditions is beyond the scope of this work and will be presented elsewhere). All of the graphene grains shown in Fig. 1b appear to have orientations (edge directions) closely aligned with each other, which would suggest some well defined epitaxial relation between the graphene lattice and that of underlying Cu grain. However, a closer examination of the image reveals that the alignment is in fact not precise. Furthermore, we have also frequently observed situations where the individual graphene grains grown within a single Cu grain have very different orientations with each other, as shown in Fig. 1c. The lack of correlation between the crystal orientation of the graphene and the underlying Cu indicates that the interaction between the graphene and Cu is weak, and that there is no definite epitaxial relationship between the two. Recent experimental (scanning tunnelling microscopy (STM); ref. 23) and theoretical (van der Waals-density functional calculation)²⁴ studies of graphene on single-crystal Cu(111) have also found a very weak graphene–Cu interaction. Interestingly, we have found that individual graphene grains can be grown continuously (without any apparent distortion of its hexagonal shape) across Cu grain boundaries, as shown in Fig. 1d (see also Supplementary Fig. S2). This phenomenon reflects the weak influence of the Cu crystal lattice on graphene growth and demonstrates that single-crystalline graphene can grow on polycrystalline Cu.

Establishing the crystal structure and orientation of the graphene grains is relatively straightforward using transmission electron microscopy (TEM). The graphene grains used in the measurements were transferred to ~ 100 nm thick amorphous SiN membranes.

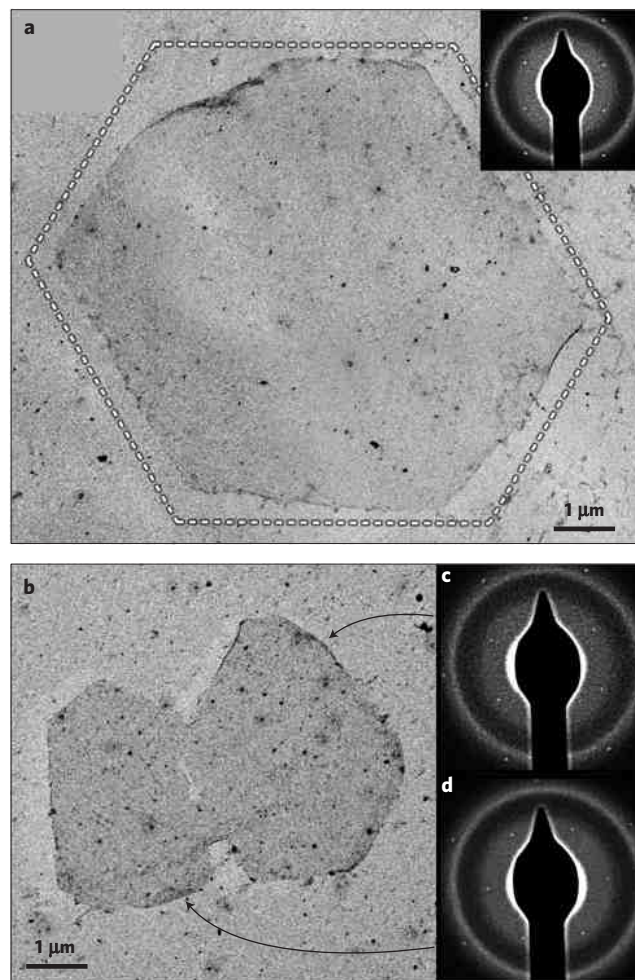


Figure 2 | Transmission electron microscopy and electron diffraction from graphene grains. **a**, A montage of bright field TEM images (80 kV) spliced together to show an example of a graphene grain. A schematic outline has been included based on the adjoining SAED pattern (inset) to demonstrate that the edges of the graphene grains are mostly parallel to the zigzag directions (dashed lines). The edges typically curl as a result of the transfer from the growth substrate to a TEM-compatible support. **b**, Bright field TEM image of two coalesced grains and SAED patterns (**c,d**) from the individual grains demonstrate that each corresponds to a single crystal of graphene, and that the two grains are rotated from each other by approximately 28° . The SAED patterns have been filtered (the unfiltered versions are shown in Supplementary Fig. S4) to improve the contrast over the diffuse background, contributed mostly by the amorphous SiN support. The dark pointer in each pattern is the shadow of the beam stop used to block the intense direct beam.

Figure 2a shows a TEM image of a hexagonally shaped graphene grain and its characteristic selected area electron diffraction (SAED) pattern (inset). Only one set of six-fold symmetric diffraction spots was observed, indicating that the grain is a single crystal. There was occasionally a small degree of arc to the diffraction spots collected from larger graphene grains. This can be attributed to cracks, folds, tears or residues caused by the transfer process. One can also determine the crystal direction of a grain's edges by comparing the orientation of the grain in real space with the orientation of the diffraction pattern (as shown schematically in Supplementary Fig. S3). We found that most of the grain edges (despite their microscopic roughness) were approximately aligned with zigzag directions (indicated by dashed lines in the example of Fig. 2a), whereas armchair directions were seen only very rarely. Sometimes

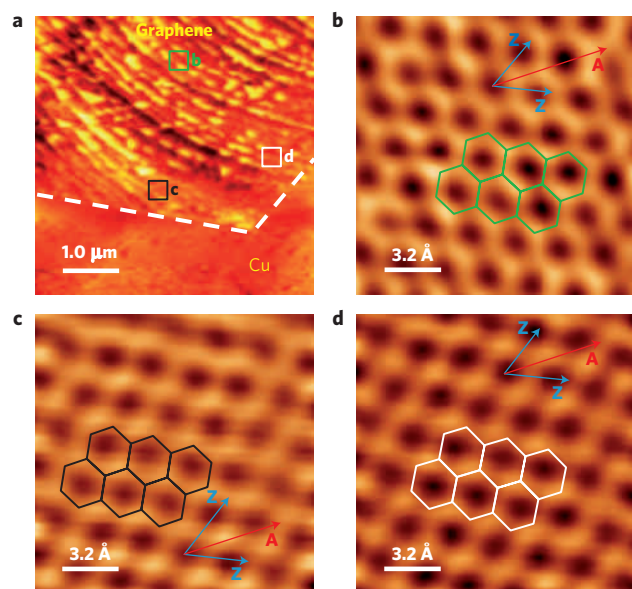


Figure 3 | Scanning tunnelling microscopy of a single-crystal graphene grain on Cu. **a**, STM topography image taken near a corner of a graphene grain on Cu. The image was acquired with a sample–tip bias $V_b = -2$ V and tunnelling current $I = 50$ pA. Dashed lines mark the edges of this grain. **b–d**, Atomic-resolution STM topography images (filtered to improve contrast) taken from three different areas in the grain as indicated in **a**. The green (**b**), black (**c**) and white (**d**) squares (not to scale) indicate the approximate locations where the images were taken ($V_b = -0.2$ V, $I = 20$ nA). A few model hexagons are superimposed on the images to demonstrate the graphene honeycomb lattice. Select special crystal directions ('Z' for zigzag, 'A' for armchair) are indicated by arrows. A small distortion in images **c** and **d** was due to a slight hysteresis in the movement of the STM tip. The corresponding unfiltered raw images of **b–d** are shown in Supplementary Fig. S7.

the edges were partially folded or torn, as also seen in Fig. 2a, a feature not uncommon in our samples and likely a result of the transfer process (notably, this also limits our ability to obtain atomic-resolution TEM images of the edge structure). Additional examples of graphene grains and their edge orientations (as determined by TEM/SAED) can be found in Supplementary Fig. S5. Figure 2b presents a TEM image of two coalescing graphene grains with Fig. 2c,d showing their respective SAED patterns. Although each grain is seen to be a single crystal, the crystal orientations of the two are rotated from each other (by $\sim 28^\circ$ in this case).

Figure 3 presents STM images taken from a representative graphene grain grown on Cu. A large-scan-area STM topography image of the grain near a corner is shown in Fig. 3a. The angle between the two edges (indicated by the dashed lines) is $\sim 120^\circ$. At this length scale, we found that the graphene surface showed significant roughness and height fluctuation (on the order of 10 nm, see Supplementary Fig. S6). Figure 3b–d show atomically-resolved STM topography images (filtered to improve contrast) taken from three different locations (marked by different colour squares in Fig. 3a) in the graphene grain. The sample orientation and the scanning orientation were kept the same as used in Fig. 3a. The characteristic honeycomb lattice (highlighted with a few model hexagons superimposed on the images) of single layer graphene can be clearly observed. The three images show the same lattice orientation (within our experimental uncertainty related to a small tip motion hysteresis and sample/tip drift), consistent with the single-crystalline nature of the grain. Furthermore, the two edges in Fig. 3a are seen to each be parallel to a zigzag direction in the graphene lattice (Fig. 3b–d, where we have indicated two

zigzag ('Z') and one armchair ('A') directions with correspondingly labelled arrows). Our STM results thus confirm that the graphene grain studied is a single layer, and that it is single-crystalline with edges along zigzag directions.

The relative stability of two types of edges along major crystallographic directions in graphene (zigzag versus armchair) has been a question under active investigation, both experimentally^{25–28} and theoretically^{29–31}. For example, exfoliated monolayer graphene flakes can show both zigzag and armchair oriented edges^{1,32}. On the other hand, edges created by certain etching reactions²⁷, or in holes formed by electron beam irradiation²⁵ in graphene, appear to favour zigzag directions. Previously studied graphene 'nanograins' (with sizes much smaller than those studied here) that were epitaxially grown on various single-crystal metal surfaces^{33–35} show mostly zigzag edges, whereas those grown on SiC(0001) show armchair edges²⁸. Such a rich array of behaviour suggests that the relative stability of zigzag versus armchair edges may be strongly influenced by the graphene's environment (such as the substrate). Our findings indicate that zigzag edges are also preferred in graphene grown on polycrystalline Cu (even when definite epitaxial relations may not exist). Furthermore, as our relatively large sized graphene grains (spanning tens of micrometres) have macroscopically zigzag-oriented edges (serving as intrinsic 'direction markers'), such grains may facilitate the study of crystal direction-dependent physics in graphene^{36–38} and the fabrication of graphene nanostructures with well-defined edge orientations.

Raman spectroscopy is a powerful technique to identify the number of graphene layers and the presence of defects in graphene^{39–41}. We have performed Raman spectroscopy and mapping with a 532 nm excitation laser on CVD-grown graphene grains transferred onto SiO₂/Si wafers (see Methods). The intensities (I_x , where $x = D, G$ or $2D$) of characteristic graphene Raman peaks³⁹, D ($\sim 1,350$ cm⁻¹), G ($\sim 1,580$ cm⁻¹) and $2D$ ($\sim 2,690$ cm⁻¹) were extracted and their spatial dependences (Raman maps) are plotted in Fig. 4a–c for a single graphene grain, and in Fig. 4d–f for two coalesced graphene grains, respectively. Several representative Raman spectra are also shown in Supplementary Fig. S8. The typical I_{2D} is more than twice that of I_G , indicating that our samples are single layer graphene^{9,11,39}. Furthermore, I_D (see also 3D plots in Supplementary Fig. S9) is negligibly small (indicating a low defect content^{39–41}) over most of the area within each graphene grain, with the notable exception of a few isolated spots displaying relatively large I_D (for example location 'c' in Supplementary Fig. S8), indicating defects. We have mapped many (>20) graphene grains and found that every grain contains at least one such defect spot (with large I_D). We suggest that some of these defect sites could be nucleation centres, that is, where the growth is initiated. A pronounced I_D was also observed on the edges of the grains, consistent with previous Raman studies of graphene edges^{39–41}, as well as at the grain boundary between two coalesced grains (Fig. 4d and Supplementary Fig. S8). Raman mapping of the D peak intensity provides a particularly convenient way to clearly identify the locations of grain boundaries (which are otherwise more difficult to visualize, for example, in SEM images shown in Fig. 1, and the atomic force microscope (AFM) image shown in Supplementary Fig. S10). The Raman D peak indicates an (elastic) intervalley scattering process^{39,40}. Our observation of large I_D at the grain boundaries suggests that they are a significant source of intervalley scattering, which gives prominent signatures (weak localization) in the electronic transport measurements to be presented next.

Electrical transport measurements were performed on multi-terminal devices fabricated from graphene grains transferred onto SiO₂/Si wafers (Methods). Figure 5a shows a representative device ('a') fabricated on two coalesced graphene grains that meet at a single grain boundary. Multiple electrodes were patterned to contact each grain to allow simultaneous measurements of both

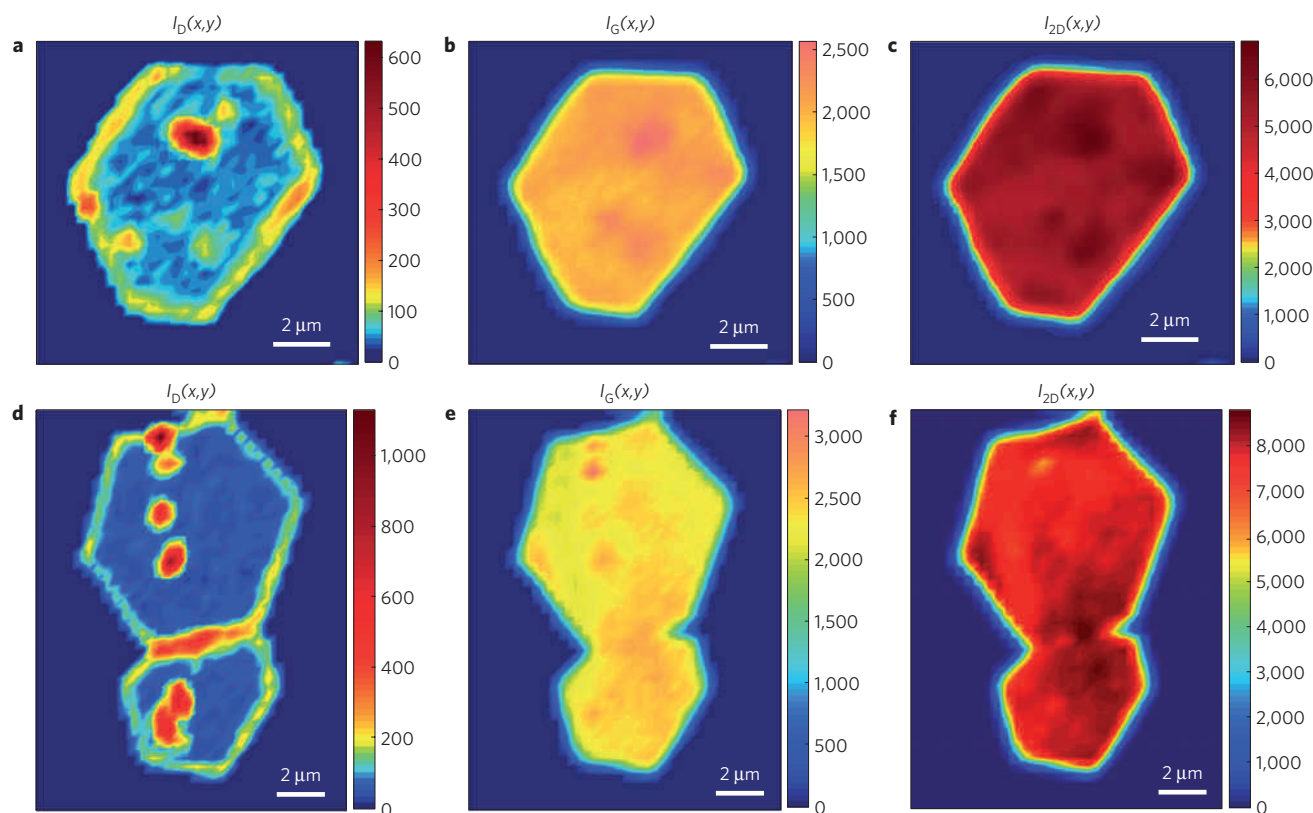


Figure 4 | Spectroscopic Raman mapping of graphene grains and grain boundaries. **a–c**, Intensity maps of the ‘D’, ‘G’ and ‘2D’ bands, respectively, for a single-crystal graphene grain. **d–f**, Intensity maps of the ‘D’, ‘G’ and ‘2D’ bands, respectively, for two coalesced graphene grains with a single grain boundary. The wavelength of the Raman excitation laser is 532 nm. The spectral resolution is 2.5 cm^{-1} . The Raman map pixel size is $0.4\text{ }\mu\text{m}$.

intra-grain (within the grain) and inter-grain (across the grain boundary) transport. Figure 5b shows representative intra-grain and inter-grain current–voltage (I – V) curves measured at room temperature for this device. All the I – V curves are linear (ohmic). The resistances extracted from the slopes of these I – V curves are $R_L \sim 550\text{ }\Omega$ (left grain), $R_R \sim 200\text{ }\Omega$ (right grain) and $R_{CG} \sim 3\text{ k}\Omega$ (across the grain boundary), respectively. Taking into account of the device geometry, we can extract from R_{CG} an effective inter-grain resistivity (based on a geometric average of the sample width, see Supplementary Fig. S11) of $\rho_{CG} \sim 5\text{ k}\Omega\text{ }\square^{-1}$. This is higher than both of the intra-grain resistivities ($\rho_L \sim 2,000\text{ }\Omega\text{ }\square^{-1}$ for the left grain and $\rho_R \sim 400\text{ }\Omega\text{ }\square^{-1}$ for the right grain, extracted from the corresponding resistances above), reflecting the effect of the grain boundary to impede the electrical transport. We can also calculate an inter-grain series resistance (r) that neglects the grain boundary, by integrating the intra-grain resistivities (see Supplementary Fig. S11). This gives $r \sim 0.9\text{ k}\Omega$, much smaller than the measured $R_{CG}(\sim 3\text{ k}\Omega)$, indicating that the grain boundary provides an ‘extra’ resistance ($\sim 2.1\text{ k}\Omega$ in this case). We have found qualitatively similar results in all of the coalesced grain devices we have measured (Supplementary Fig. S12): inter-grain resistivities (ρ_{CG}) are always higher than corresponding intra-grain resistivities (ρ_G , on each side of the grain boundary), and inter-grain resistances (R_{CG}) are always higher than the calculated inter-grain series resistances (r).

Magnetotransport measurements were performed for device ‘a’ under a perpendicular magnetic field (B). Figure 5c presents low temperature (4.3 K) magnetoresistance ($R_{xx}(B)$) measurements across the grain boundary compared to $R_{xx}(B)$ measured within each of the graphene grains. The inter-grain $R_{xx}(B)$ displays a prominent peak at $B = 0\text{ T}$, associated with weak localization (WL). Such a WL peak was much weaker or even unobservable for intra-grain $R_{xx}(B)$. Similar results were found in multiple

devices, and an example for another device (‘b’) measured at an even lower temperature of 450 mK is shown in Supplementary Fig. S13. Weak localization results from the interplay between impurity scattering and quantum coherent transport of carriers (such an interplay also leads to reproducible ‘universal conductance fluctuations’ (UCF) in the resistance⁴², which were also observable in our devices). Raising the temperature (T) is expected to destroy the phase coherence, and thus diminish the WL feature, as was indeed observed (Fig. 5d, showing temperature dependence of the inter-grain $R_{xx}(B)$). The inter-grain WL feature we observed at low temperature can be well fitted to the WL theory developed for graphene⁴³, allowing us to extract various inelastic (phase-breaking) and elastic (intervalley and intravalley) scattering lengths (Supplementary Fig. S14). In graphene, because of the chiral nature of carriers^{43–45}, WL requires the presence of sharp lattice defects that cause intervalley scattering with large momentum (q) transfer. Our observation of prominent inter-grain WL but much weaker or negligible intra-grain WL indicates that grain boundaries are major sources of intervalley scattering in our graphene devices (where the inter-grain current has to cross the grain boundary), whereas such scattering is less significant within the single-crystal graphene grains. This is consistent with the relatively large value of intervalley scattering length L_i ($\sim 200\text{ nm}$) extracted from the low T weak localization fitting (Supplementary Fig. S14), as a carrier would have to encounter a grain boundary, a graphene edge, or some other isolated and more localized lattice defects within the grain to undergo intervalley scattering.

The intra-grain mobility (μ_G) extracted from low temperature Hall measurements in all of the devices we studied (fabricated on isolated as well as coalesced grains) ranged from $<10^3\text{ cm}^2\text{ V}^{-1}\text{ s}^{-1}$ to $\sim 10^4\text{ cm}^2\text{ V}^{-1}\text{ s}^{-1}$. The devices were all found to be p-type doped (probably owing to adsorbates from the environment and residues

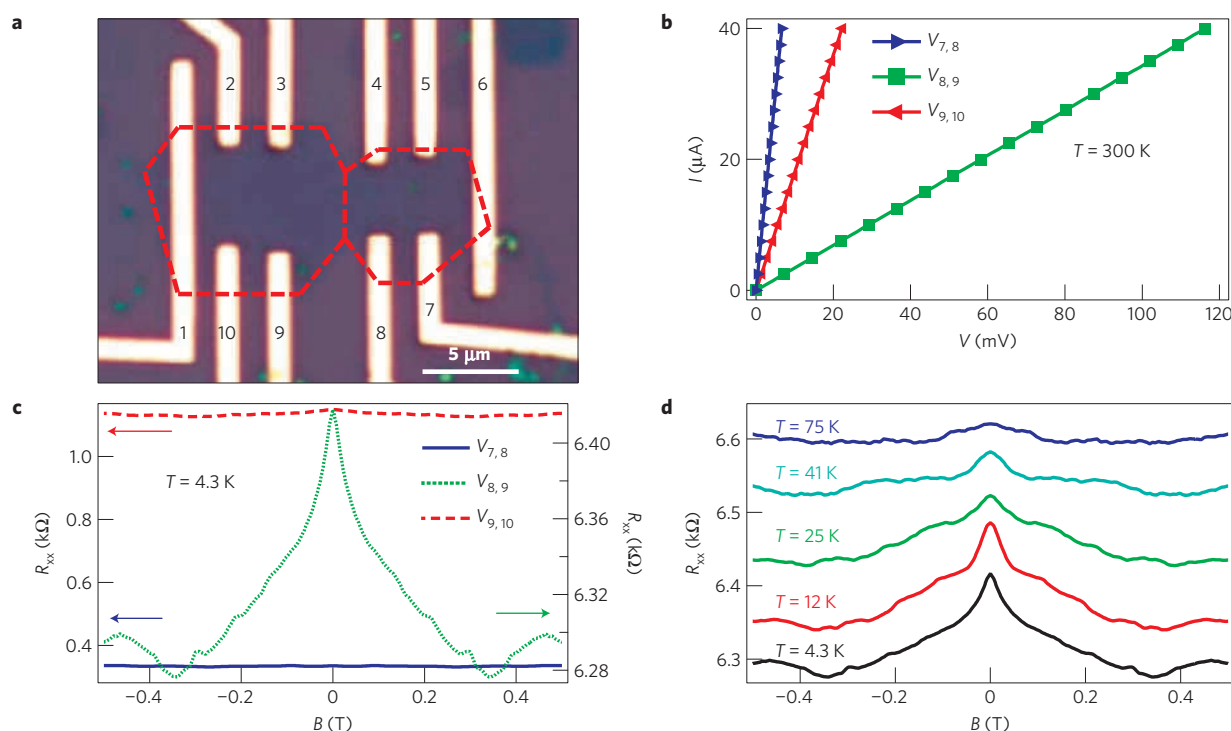


Figure 5 | Electronic transport cross a single grain boundary. **a**, Optical image of a device with multiple electrodes (numbered 1–10) contacting two coalesced graphene grains (indicated by dashed lines). **b**, Representative room-temperature I - V curves measured within each graphene grain and across the grain boundary. The measurements shown were performed at zero magnetic field, and using four-probe configurations, with contacts '1' and '6' as current leads, and the 3 pairs of voltage leads labelled in the legend. **c**, Four-terminal magnetoresistance (R_{xx}) measured at 4.3 K within each graphene grain and across the grain boundary (using the same set of contacts as in **b**). The inter-grain R_{xx} (dotted curve) displays a prominent weak localization (WL) peak. **d**, Temperature dependence of the WL feature (**c**) in the inter-grain R_{xx} . Traces are offset vertically for clarity. R_{xx} data in **c,d** have been symmetrized between two opposite magnetic field directions to remove a small linear background from a mixing of Hall component.

from the transfer and device fabrication processes). Inter-grain mobility was not extracted, as the two coalescing grains often had different carrier densities (in the cases where their densities were comparable, the inter-grain mobility was lower than μ_G by factors similar to the resistivity ratios shown in Supplementary Fig. S12a). Our work has clearly indicated the detrimental effect of grain boundaries on electronic transport, and that avoiding grain boundaries is beneficial for improving the mobility. However, the wide variation of μ_G in different samples (sometimes even between neighbouring grains) and the occasional low μ_G observed suggest that other sources of disorder could also strongly affect the mobilities. Such 'extra' disorder may also be partially responsible for the small intravalley scattering length ($L_s < 20$ nm, Supplementary Fig. S14) observed (indicating a significant amount of small- q scattering defects such as charged impurities, line defects and ripples^{2,43,45} that may arise from, for example graphene transfer or device fabrication processes¹³). Improving related fabrication processes to reduce such defects will be required to achieve consistently high mobilities in graphene-based devices.

It is desirable to avoid grain boundaries when fabricating graphene devices, as they have a detrimental effect on graphene's electronic properties and device performance. This would be very difficult to achieve for a large number of graphene devices in a practical circuit if the graphene grains nucleate at random locations, as shown in Fig. 1. Here we demonstrate a method to control the nucleation of graphene grains using seeded growth, and to synthesize spatially ordered arrays of graphene grains with pre-determined locations (Fig. 6). Seeded growth is commonly used in the growth of single-crystal materials (for example the well-known Czochralski process used to create single-crystal Si (ref. 19). Unlike the previously discussed growth of randomly

nucleated graphene grains (Fig. 1), here seed crystals were placed on Cu as nucleation centres. Figure 6a shows an example array of seed crystals lithographically patterned from a continuous multilayer graphene film pre-grown by CVD on a Cu foil^{46,47}. Following patterning, the Cu foil was re-inserted into the CVD furnace to perform re-growth. Figure 6b and c show typical results after seeded growth with a shorter and longer growth time, respectively, giving rise to smaller and larger average grain sizes. Monolayer graphene (confirmed by Raman spectroscopy) grains have been successfully synthesized from seed crystals made of either multilayer or monolayer CVD graphene as well as transferred exfoliated graphene/graphite. Seeds made from multilayer CVD graphene have mostly been chosen thus far, being both easy to pattern into large area seed arrays and sufficiently robust to withstand the patterning process. From Fig. 6b and c, it is apparent that the seeded growth resulted in largely ordered arrays of graphene grains, with each grain growing from a seed crystal (many of the seeds were still visible inside the synthesized grains shown in Fig. 6b). In Fig. 6d, we compare seeded grains with randomly nucleated grains grown concurrently on the same Cu foil (which has a pre-patterned seed array to the left of the dashed line, and no seeds to the right). The seeded growth led to mostly ordered arrays of grains of a much higher density than the randomly nucleated grains. In our seeded growth demonstrated so far, randomly nucleated (that is, non-seeded) grains were also occasionally (but more rarely) observed (for example in Fig. 6d, as well as a particular example in Fig. 6b marked by the arrow at the lower left). Occasionally, multiple (merged) grains, apparently growing from a single shared seed, were also observed. These observations may reflect the competition between seeded growth and randomly-nucleated growth, and possible effects of the seeds we used. More work is under way to

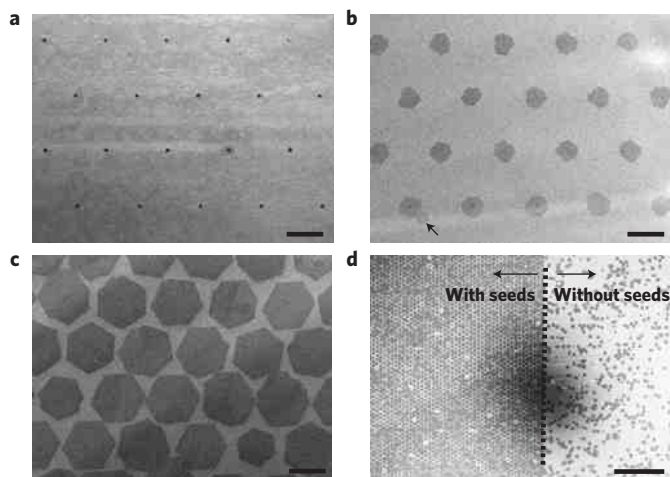


Figure 6 | Seeded growth of graphene grains. **a**, SEM image showing an array of seed crystals (seen as dots) patterned from a pre-grown multilayer graphene film on Cu foil by e-beam lithography. The period of the array is 16 μm . The size of each seed is about 500 nm. **b**, SEM image of a typical graphene grain array grown from an array of seed crystals, with a relatively short growth time (5 min). The seeds can be seen at the centres of many grains. A grain that nucleated randomly (that is not from one of the pre-patterned seeds) is also observed (indicated by the arrow at the lower left). **c**, SEM image of a graphene grain array from seeded growth similar to **b**, but following a longer growth time (15 min). The representative images **a–c** do not necessarily correspond to the exactly the same area on the Cu foil. **d**, Low magnification SEM image of a seeded array of graphene grains (to the left of the dotted line), next to a randomly-nucleated set of graphene grains in an area without seeds (to the right of the dotted line). Scale bars in **a–c** are 10 μm and the scale bar in **d** is 200 μm . To reduce Cu surface defects that could create random (not from seeds) nucleation of graphene grains, the Cu foil was annealed for 3 h before the seeded growth.

determine whether and how different types and properties of seeds may affect the seeded growth, and to further improve the yield of seeded single-crystal graphene grains. Compared with the regular CVD growth of graphene based on random nucleation studied earlier, the seeded growth demonstrated here could offer a viable strategy to control the nucleation of graphene crystals, making an array of many graphene grains with pre-determined locations. Such an addressable graphene grain array could facilitate large-scale fabrication of single crystalline graphene electronic devices that avoid grain boundaries altogether, without the need of starting with a large single-crystalline graphene sheet (then subject to subsequent etching and patterning).

In conclusion, we have synthesized hexagonally shaped graphene single-crystal grains of up to tens of micrometres in size on polycrystalline Cu. The single-crystal nature of these graphene grains is confirmed by TEM and STM, and their edges are found to be predominantly parallel to zigzag directions. Individual grain boundaries are characterized and found to cause weak localization and impede electrical transport. We have also demonstrated that single-crystal graphene growth is not limited by the polycrystallinity of the Cu substrate and can be artificially initiated by a seed, paving the way for controllable synthesis of single-crystal graphene and large scale fabrication of single-crystalline graphene devices free of grain boundaries.

Methods

Graphene synthesis and transfer. Graphene grains were grown by CVD (CH_4 as the carbon feedstock) on Cu substrates at ambient pressure. First, a Cu foil (25- μm -thick, 99.8%, Alfa Aesar) was loaded into a CVD furnace and heated up to 1,050 $^\circ\text{C}$ under 300 s.c.c.m. Ar and 10 s.c.c.m. H_2 . After reaching 1050 $^\circ\text{C}$, the sample was annealed for 30 min or longer without changing the gas flow rates.

The growth was then carried out at 1,050 $^\circ\text{C}$ for ~ 10 min under a gas mixture of 300 s.c.c.m. diluted (in Ar) CH_4 (concentration 8 ppm) and 10 s.c.c.m. of H_2 . Finally, the sample was rapidly cooled to room temperature under the protection of Ar and H_2 , then taken out of the furnace for characterization. Graphene samples were transferred by a PMMA (polymethyl methacrylate)-assisted process in a Cu etchant (iron nitrate) onto ~ 100 nm thick amorphous Si_3N_4 membranes (chosen for their flat surface over large areas) for TEM studies, or onto SiO_2/Si wafers (doped Si covered by 300 nm SiO_2) for Raman and electrical transport studies.

Transmission electron microscopy. All TEM images were taken at 80 kV on an FEI Tecnai 20. Selected area electron diffraction (SAED) patterns and bright field images were taken in plan view, with the beam at or near parallel to (0001) for the graphene. Montages are spliced together from individual bright field images using a 2D stitching plugin (<http://fly.mpi-cbg.de/~preibisch/software.html>) with Fiji⁴⁸. To enhance the contrast between the graphene reflections and background (from amorphous SiN) in diffraction patterns, a mild low pass filter was sometimes applied (> 3 pixels), followed by a locally adaptive histogram equalization filter (50 pixel blocksize, 256 histogram bins, max. slope 8.0; refs 48,49). Nonetheless, graphene diffraction spots are quite clear in the original, unfiltered patterns when viewed at full size (see Supplementary Fig. S4). SAED patterns examined from multiple areas in each grain, and when possible from a larger area including the entire grain, demonstrate that the grains studied are primarily single-crystalline graphene.

Scanning tunnelling microscopy. STM measurements were carried out in an Omicron ultra-high vacuum (UHV, base pressure $< 10^{-11}$ mbar) scanning tunnelling microscope at room temperature (300 K). Before the measurements, the sample was annealed in UHV at 300 $^\circ\text{C}$ for 12 h to remove the surface adsorbates and contaminants. The chemically etched STM tip was made of tungsten or platinum/iridium alloy and was also annealed before imaging. The atomic resolution images have been processed with a wavelet-based filter⁵⁰ to enhance the contrast.

Raman spectroscopy and mapping. Raman spectroscopy and spatial Raman mapping were performed using a Horiba Jobin Yvon Xplora confocal Raman microscope equipped with a motorized sample stage from Marzhauser Wetzlar (00-24-427-0000). The wavelength of the excitation laser was 532 nm and the power of the laser was kept below 2 mW without noticeable sample heating. The laser spot size was $\sim 0.6 \mu\text{m}$ with a $\times 100$ objective lens (numerical aperture = 0.90). All the Raman maps had a pixel size of 0.4 μm for both x and y directions. The spectral resolution was 2.5 cm^{-1} (using a grating with 1,200 grooves mm^{-1}) and each spectrum was an average of 3 acquisitions (5 s of accumulation time per acquisition). The intensity of a Raman peak was extracted from the maximum value after baseline subtraction over corresponding spectral range (1,300–1,400 cm^{-1} for 'D', 1,560–1,600 cm^{-1} for 'G' and 2,620–2,760 cm^{-1} for '2D').

Device fabrication and electronic transport measurements. The electrical contacts (Cr/Au, 5 nm/35 nm, e-beam evaporated) to graphene grains were patterned by e-beam lithography. No oxygen plasma etching for patterning graphene was performed to avoid introducing extra defects in graphene. The resistances (Fig. 5c and d) were measured using low-frequency lock-in detection (SR 830) with a driving current of 1 μA . The I - V curves in Fig. 5b were measured with a d.c. source meter (Keithley 2400). All the electrical transport data in the main text were taken in vacuum ($\sim 10^{-3}$ torr) in a variable temperature probe station (Lakeshore CPX-VF).

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Author contributions

W.W., R.C. and J.T. are equally contributing second authors. Q.Y. led the synthesis and Y.P.C. led the characterization efforts. Q.Y., W.W., Z.L. and Z.S. synthesized the graphene samples and performed SEM. R.C. and E.A.S. performed the TEM. J.T., H.C. and N.P.G. performed the STM. L.A.J. performed the Raman measurements. L.A.J. and H.C. fabricated the devices and performed electronic transport measurements. Q.Y., L.A.J., R.C., J.T., E.A.S. and Y.P.C. wrote the paper and all authors contributed to the discussions.

Additional information

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